



Docket No.: SON-2413/DIV  
(PATENT)

DPW

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Patent Application of:

Shigeru Moriya, et al.

Confirmation No.: 3815

Application No.: 10/689,098

Art Unit: 1756

Filed: October 21, 2003

Examiner: Stephen D. Rosasco

For: **MASK, METHOD OF PRODUCING MASK,  
AND METHOD OF PRODUCING  
SEMICONDUCTOR DEVICE**

**SUPPLEMENTAL AMENDMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

**INTRODUCTORY COMMENTS**

In full and timely further response to the Official Action dated March 13, 2006, please supplement the prior amendment to the above-identified U.S. patent application as follows:

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks/Arguments** begin on page 7 of this paper.